



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 9938**  
Hiroshi TAKANASHI et al. : **Docket No. 2001-0476**  
Serial No. 09/838,118 : **Group Art Unit 1752**  
Filed April 20, 2001 : **Examiner S. Lee**

NEGATIVE-WORKING PHOTSENSITIVE :  
RESIN COMPOSITION AND PHOTSENSITIVE  
RESIN PLATE USING THE SAME

THE COMMISSIONER IS AUTHORIZED  
TO CHARGE ANY DEFICIENCY IN THE  
FEES FOR THIS PAPER TO DEPOSIT  
ACCOUNT NO. 23-0975

PETITION FOR EXTENSION OF TIME

Assistant Commissioner for Patents,  
Washington, DC 20231

Sir:

Petition hereby is made for a three month extension of time to respond to the communication of  
August 14, 2002.

The fee of \$930.00 is

(X) submitted herewith.  
( ) to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is  
enclosed.

( ) Small entity status of this application is established by a Small Entity Status Assertion  
which

( ) is enclosed.  
( ) has been previously submitted.

02/10/2003 SZEWDIE1 00000038 09838118

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930.00 00

Respectfully submitted,

Hiroshi TAKANASHI et al.

By Matthew Jacob  
Matthew Jacob  
Registration No. 25,154  
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February 14, 2003

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